ATTORNEY DOCKET NO. 064441.0266

10-18-04 PATENT APPLICATION 1 LW 10/696,326

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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of:

Zhang et al.

Serial Number:

10/696,326

Filed:

October 29, 2003

Group Art Unit:

1756

Examiner:

Unassigned

Title:

Photomask Assembly and Method for Protecting the Same from Contaminants

during a Lithography Process

EV352374615US

MAIL STOP - AMENDMENT

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450 I hereby certify that this Information Disclosure Statement is being deposited with the United States Postal Service as Express Mail: EV352394615US addressed to: Mail Stop - Amendment, Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450, on October 15, 2004.

INFORMATION DISCLOSURE STATEMENT

Applicants respectfully request, pursuant to 37 C.F.R. §§1.56, 1.97 and 1.98, that the references listed on the enclosed PTO-1449 form be considered and cited in the examination of the above-identified application. Since the present Application was filed after June 30, 2003, a copy of any U.S. Patent cited on the attached PTO Form 1449 is not being submitted with this Information Disclosure Statement pursuant to the July 11, 2003 waiver of 37 C.F.R. §1.98(A)(2)(i) by the U.S. Patent and Trademark Office. Furthermore, pursuant to 37 C.F.R. §§1.97(g) and (h), no representation is made that these references are material to the patentability of the present application.

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Applicants believe no fees are due, however, the Commissioner is hereby authorized to charge any fees or credit any overpayments to Deposit Account No. 50-2148 of Baker Botts L.L.P.

Respectfully submitted,

BAKER BOTTS L.L.P.

Attorneys for Applicants

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Date: October 15, 2004

PTO-1449

OCT 1 5 2004

Information Disclosure Citation in an Application দেশ
 Application No.
 Applicant(s)

 10/696,326
 Zhang et al.

 Docket Number
 Group Art Unit | Filing Date

 064441.0266
 1756
 10/29/2003

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K.	4833051	05/23/89	Imamura	430	5	12/17/87
L.	4948851	08/14/90	Squire	526	247	12/28/89
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EXAMINER

DATE CONSIDERED

EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP § 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to the applicant.

PTO-1449 Information Disclosure Citation in an Application			Application No.		Applicant(s)				
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